## **Questionnaire of edaWorkshop15** and CATRENE DTC

May 19 - 21, 2015, Dresden, Germany



1. Keynotes							
Semiconductor Technologies & Smart Cities – Technology Push or Application Pull? (J. Pelka) May 19	excellent	0	0	0	0	0	unsufficient
System of Systems – The Key Enabler for Future Applications (A. Schöllhorn) May 20	excellent	0	0	0	0	0	unsufficient
Design of Secure Chips (G. Sigl) May 21	excellent	0	0	0	0	0	unsufficient
2. Invited Presentations							
ENI <sup>2</sup> : Defining Research Key Topics to Support Europe's Ambition in Nanoelectronics (P. Cogez) May 19	excellent	0	0	0	0	0	unsufficient
Design for Manufacturing in Extreme Scaling and Beyond (D. Pan) May 21	excellent	0	0	0	0	0	unsufficient
From Material via SOC to Systems/Platforms: The Design Roadmap in ECSEL MASP (H. Daembkes) May 21	excellent	Ο	Ο	Ο	Ο	Ο	unsufficient
3. Sessions							
Connected Objects (May 19)	excellent	Ο	Ο	Ο	Ο	Ο	unsufficient
Energy Efficient MPSoC (May 19)	excellent	Ο	Ο	Ο	Ο	Ο	unsufficient
Modeling and Simulation (May 20)	excellent	Ο	Ο	Ο	Ο	Ο	unsufficient
FDSOI Ecosystems (May 20)	excellent	Ο	Ο	Ο	Ο	Ο	unsufficient
Security, Safety and Privacy – Challenges and Design Solutions for Tomorrow's Applications (May 20)	excellent	0	0	0	0	0	unsufficient
V2X: Car to Environment Communication (May 20)	excellent	Ο	Ο	Ο	Ο	Ο	unsufficient
MEMS and Analog (May 21)	excellent	Ο	Ο	Ο	Ο	Ο	unsufficient
Strategy, Analysis and Diagnosis (May 21)	excellent	0	0	0	0	0	unsufficient
4. Panel Discussions							
ENI <sup>2</sup> Roadmap, Make it Happen; Smart Transportation as a Use Case (May 19)	excellent	0	0	0	0	0	unsufficient
5. Poster Exhibition (May 20 - 21)							
The poster exhibition was	excellent	0	Ο	0	Ο	0	unsufficient

please turn over

I knew x percent of the conference locat			excellent	0	0	0	0	0	unsufficient
My expectations were more than fulfilled		completely agree		0	0	0	0	completely disagre	
The overall impression was good		completely agree		0	0	0	0	completely disagre	
7. About the joint	event "edaW	orkshop15	and CATRENE DTC	,					
I have been participa	nt at an edaWor	kshop before			yes	s 0	Ο	no	
I have been participal (formerly MEDEA+ D		E DTC before			yes	s O	0	no	
The co-location of bo	th events is a go	ood idea	completely agree	0	Ο	Ο	Ο	0	completely disagre
I will participate next	year's edaWork	shop	in any case	0	Ο	Ο	Ο	0	not at all
I will participate next	year's CATREN	E DTC	in any case	0	0	0	0	0	not at all
8. Main reasons fo	or attendance	(multiple c	hoices possible)						
O Refresh existing contacts O Speaker/exhibitor			exhibitor	O edaWorkshop15					
O Make new contacts O Technical			l interest	ost O CATRENE DTC					
O Other:									
9. How did you ge	t to know ab	out the eda	Workshop15 and C	ATRE	NE DI	<b>C</b> ?			
O E-Mail	0 www		O Mail	O Mail O Facebook/Twitter/LinkedIn			edIn		
O Press	O Colleague	es/Friends	O Known from last y	) Known from last year's event					
O Other:									
10. More commen	ıts								
O Other:				rear's	event				

## Many thanks for completion the questionnaire!

Please return this form to the registration desk before leaving or fax it to **+49 511 762-19695**.